Therm odynam ic driving force of form ation of coherent three-dim ensional islands in Stranski-K rastanov grow th

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The form ation of coherent three-dimensional islands in highly m ism atched epitaxy is discussed in terms of the traditional concept of wetting. It is shown that the wetting layer and the 3D islands represent dierent phases which cannot be in equilibrium with each other. The transfer of m atter from the stable wetting layer to the 3D islands is therm odynam ically unfavored. The experimentally observed critical m is t for coherent 3D islanding to occur and the coexistence of pyram ids with discrete heights of two, three, four... monolayers can be explained assuming that the therm odynam ic driving force of form ation of coherent 3D islands on the surface of the wetting layer of the same m aterial is the reduced average adhesion of the islands to that layer and that the islands height is a discrete variable.

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The growth of thin epitaxial Ims usually takes place far from equilibrium . Nevertheless, therm odynam ic considerations are a necessary step for understanding of the process. Of particular interest is the therm odynam ic driving force (TDF) which is responsible for one or another mechanism of growth. W hile this question is well understood in terms of wetting of the substrate by the overgrow th in the cases of island or Volm er-W eber (VW) growth and layer-by-layer or Frank-van der Merwe (FM) growth,^{1,2,3} the Stranski-K rastanov (SK) growth (3D islands on top of a thin wetting layer) is far from being claried. The reason is that the SK growth is in fact a grow th ofm aterialA on the sam em aterialA, which therm odynam ically requires the form ation and grow th of 2D rather than 3D islands. This is particularly true in the case of the coherent Stranski-K rastanov grow th,⁴ w here dislocation-free 3D islands are strained to the sam e degree as the wetting layer.^{4,5,6} T his is the reason why it is widely accepted that the energy of the interfacial boundary between the 3D islands and the wetting layer is equal to zero.⁷ A lthough this energy is expected to be small. com pared with that of the free crystal faces,⁸ it should not be neglected since this is equivalent to the assum ption that the islands wet completely the wetting layer. The latter rules out 3D islanding from a therm odynam ic point of view .9

The need for a therm odynam ic analysis arises also from the experim ental observations of a criticalm is t for coherent 3D islanding to occur, 10,11,12,13 and the sim ultaneous presence of islands of di erent thickness which vary by one m onolayer. 14,15 The existence of a criticalm is t, as well as of stable two, three or four m onolayers thick islands, do not follow from the tradeo 7,8

$$E C^{0} V^{2=3} C^{0} u^{2} V$$
(1)

between the cost of the additional surface energy and

the gain of energy due to the elastic relaxation of the 3D islands relative to the wetting layer (V , and "_0 are the islands volume, the speci c surface energy and the lattice m is t, respectively, and C 0 and C 0 are constants).

It was recently suggested that the TDF for coherent 3D islanding is the incom plete wetting of the substrate by the islands, 16 rather than the elastic relaxation of the m aterial in the islands. The incom plete wetting is due to the displacem ents of the atom snear the island edges from the bottom s of the corresponding potential troughs provided by the wetting layer. This results in a series of critical volum es at which the monolayer high islands become unstable against the bilayer islands, the bilayer islands against the trilayer islands, etc. Them is t dependence of the rst critical size N 12 for the m ono-bilayer transform ation displays a critical behavior in the sense that coherent 3D islands can be form ed at a m is t higher than som e critical value. Below this value the lm should grow in a layer-like m ode until m is t dislocations are introduced to relieve the strain. However, the approximation used by the authors, which is based on the 1D m odel of Frenkel and K ontorova,^{17,18} was unable to describe correctly the individual behavior of atom s inside each layer, since it assum es a potential with a period given by the average of the separations of atom s (considered frozen) in the layer underneath. A lthough this model gives qualitatively reasonable results concerning the energy of the islands, it is inadequate to calculate, in particular, the average adhesion energy of the islands to the wetting layer.

In the present report we recollect some simple therm odynam ic aspects of the epitaxial morphology based on the traditional concept of wetting and consider the coherent SK growth from this point of view. The same concepts were in fact advanced by Stranski in his model, adm ittedly very peculiar, of a monovalent ionic crystal K^+A on the surface of an isom orphous bivalent crystal $K^{2+}A^2$.¹⁹ We then support our therm odynam ic considerations by num erical calculations making use of a simplem inimization procedure on the same atom istic model in 1 + 1 dimensions (length + height) as in Ref.(16). The 3D islands are represented by linear chains of atom s stacked one upon the other,¹⁸ the islands height being thus considered as a discrete variable which increases by unity from one. The latter is of crucial in portance as the aspect ratio of the 3D islands is usually of the order of 0.1 and the height is of the order of 10 m onolayers.^{5,6} The atom s interact through an anharm onic M orse potential

$$V(x) = V_{o} [e^{12(x b)} 2e^{6(x b)}]$$
: (2)

The total interaction energy as well as its derivatives with respect to the atom ic coordinates, i.e. the forces, are calculated. Relaxation is then perform ed iteratively by allowing the atom s to displace in the direction of the forces until these fall below some negligible cuto value. We consider interactions in the rst coordination sphere in order to m im ic the directional bonds that are characteristic for sem iconductors.²⁰ Inclusion of further coordination spheres alters only m inim ally the num erical results. The substrate (the wetting layer) is assumed to be rigid.



FIG.1: Schematic dependence of the lm chemical potential on the lm thickness in number of monolayers for the three modes of growth: VW { Volmer-W eber, SK { Stranski-K rastanov, and FM { Frank-van der M erwe. The dashed line gives the chemical potential of the unstable wetting layer.

A mother phase (a vapor) and a new phase (e.g. a strained planar Im or unstrained 3D crystals) are in equilibrium with each other when their chemical potentials are equal. A transition from one phase (m other or new) to another takes place when the chem ical potential of one of the phases becom es smaller than that of the other. The TDF for this transition is the difference of the chem ical potentials of both phases at the given pressure and temperature. The TDF which determines the occurrence of one or another mechanism of epitaxial growth (growth from vapor of a strained 2D layer or 3D islands) is the di erence = (n) $^{0}_{3D}$ of the chem – ical potential, (n), of the overlayer which depends on the Im thickness measured in number n of monolayers counted from the interface, and the chem ical potential,

 $_{3D}^{0}$, of the bulk 3D crystal of the sam e m aterial.^{2,3} The thickness dependence of (n) originates from the thickness distribution of the m is t strain and, on the other hand, from the interaction between the deposit and the substrate, which rapidly decreases with the distance from the interface (E_{AB} ! E_{AA}).^{2,21}

If we deposit a crystal $\ensuremath{\mathsf{A}}$ on the surface of a crystal $\ensuremath{\mathsf{B}}$,

can be written in terms of the interatom ic energies per atom , E_{AA} and E_{AB} , required to disjoin a half-crystal A from a like half-crystal A and from an unlike half-crystal B, respectively $\frac{2^2}{2}$

$$(n) = {}^{0}_{3D} + [E_{AA} \quad E_{AB} (n)] = {}^{0}_{3D} + E_{AA} : (3)$$

The adhesion energy E_{AB} includes in itself the thickness distribution of the strain energy and the attenuation of the bonding with the substrate. = 1 $E_{AB} = E_{AA}$ is the adhesion parameter which accounts for the wetting of the substrate by the overgrow th. Eq. (3) is equivalent to the fam iliar 3- criterion of Bauer.^{1,21}

As follows from (3) the parameter = =E_{AA} is equal to the TDF for occurrence of one or another m ode of growth relative to the cohesive energy E_{AA} . In the two limiting cases of VW (0 < < 1) and FM growth 0, " 0), tends asymptotically with increas-(ing Im thickness to zero from above and from below, respectively, but changes its sign in the case of SK growth (< 0, " $_0 \notin$ 0), as shown in Fig. 1.^{3,21} Consider now Fig. 1 in terms of equilibrium vapor pressures instead of chem ical potentials. A lthough the connection is straightforward, (/ ln P), such a consideration gives a deeper insight into the problem $.^{19}$ Thus, as long as (n) < a thin planar Im can be deposited at a vapor pressure P that is smaller than the equilibrium vapor pressure, P_0 , of the bulk crystal, but is larger than the equilibrium vapor pressure P_1 of the rst m onolayer, i.e. $P_1 < P < P_0$. In other words, a planar lm can be deposited at under-= kT $\ln(P = P_0)$ with respect to the bulk saturation crystal. The formation of 3D islands ((n) > ${}^{0}_{3D}$) requires $P > P_0$, or a supersaturation with respect to the bulk crystal.

Applying the above considerations to the SK growth leads unavoidably to the conclusion that the 3D islands and the wetting layer represent necessarily di erent phases and thus have di erent chem ical potentials. The reason is that the two phases are in equilibrium with the mother phase (the vapor) under di erent conditions which never overlap. The wetting layer can be in equilibrium only with an undersaturated vapor phase ($P < P_0$), while small 3D islands can be in equilibrium only with a supersaturated vapor phase ($P > P_0$). The dividing line is thus = kT ln ($P = P_0$) = 0 at which the wetting layer cannot grow thicker and the 3D islands cannot nucleate and grow. Hence the wetting layer and the 3D islands can never be in equilibrium with each other.

It follows from the above that the derivative, d E = dV, of the energy of the 3D islands relative to that of the wetting layer, gives the di erence of the chem ical potentials of the wetting layer (the dashed line in Fig. 1) and the

chem ical potential of the 3D islands. In other words, it represents the di erence of the supersaturations of the vapor phase with respect to the wetting layer and the 3D islands. As the thickness and the energy of the wetting layer depend on the m is t it would be more suitable if one chooses as a reference the bulk crystal rather than the wetting layer.²³ Transfer of material from the stable wetting layer ($_{W L} < _{3D}^{0}$) to the 3D islands is connected with increase of the free energy of the system, and therefore, is therm odynam ically unfavored. A planar lm thicker than the stable wetting layer is unstable and the excess of the material can be transferred to the 3D islands if the necessary therm al activation exists.



FIG.2: Vertical displacements of the atom s of the base chain of a coherent (a) and a dislocated (b), 3 m onolayers-thick island, given in units of the lattice parameter of the wetting layer and measured from the bottom s of the potential troughs provided by the hom ogeneously strained wetting layer. The m is t " $_0$ amounts to 7% and the islands contain 30 and 34 atom s in their base chains, respectively.

W e focus our attention on the adhesion between the 3D islands and the wetting layer. Fig. 2 is an illustration of the dierence (and resemblance) between the classical and the coherent SK mode. In the calculations, the sizes of the base chain of the island (30 and 34 atom s, respectively) have been chosen just below and above the critical size for introduction of m is t dislocations at the given m is t of 7%. As seen, in both cases the 3D islands loose contact with the wetting layer. The vertical displacem ents are largest at the chain's ends in the coherent SK mode and around the dislocation cores in the classical case, but the physics is essentially the same. The mean adhesion parameter increases with the islands' height and saturates beyond severalm onolayers (Fig. 3). In our model, is calculated as the adhesion energy between island and wetting layer at the given m is t (7%) minus the corresponding value for zero mist. It can be seen that the compressed overlayers exhibit a greater tendency to coherent SK growth than expanded ones as expected, due to the anham onicity of the potential (2).

The same tendency is seen more clearly in Fig.4 which shows in fact the dependence of the TDF for form ation of coherent 3D islands, , on the lattice m is t. The latter remains close to zero for expanded overlayers but increases steeply beyond approximately 5% in compressed



FIG.3: Mean adhesion parameter as de ned by Eq. (1) as a function of the islands' height in number of monolayers for positive and negative values of the m is t of absolute value of 7%. C oherent islands of 14 atoms in the base chain were considered in the calculations.

overlayers. This behavior agrees well with the m is t dependence of the critical size, N₁₂, for the mono-bilayer transform ation to occur, as shown in Fig. 5, where a steep rise of N₁₂ with decreasing absolute value of the m is t is observed only in compressed overlayers. Note that it is less sharp for expanded ones opposite to earlier nding.¹⁶



FIG. 4: M ean adhesion parameter of one monolayer high, coherent islands as a function of the lattice m is t. The islands contain 20 atom s. D ata for both positive and negative m is ts are shown in one quadrant for easier comparison.

W e discuss now the discrete character of the height of the 3D islands. The experim entally observed volum e of the quantum dots varies roughly from 20000 to 50000 atom s.^{6,11} Typical values of the aspect ratio of the islands height and half-base are of the order of 0.1.^{6,24} Thus a pyram id with a base edge of 100 atom s and aspect ratio 0.1, and containing 22000 atom s, is only 5 m onolayers high. The addition of 14400 atoms (a new base plane of 120 atom s) requires only one more atom ic plane. 120 Calculations of the energy of islands having a shape of a frustum of a pyram id are usually perform ed assum ing implicitly that the lengths of the lower, R, and the upper, R⁰, bases, and in particular the height h, are continuous variables. Eq. (1) is obtained by using the Terso approximation which neglects the gradient of strain

in a direction norm alto the surface plane together with h = R, and assuming h = c where c is the atom ic distance.⁸ This would be correct if the crystals contain at least severalm illion of atom s.



FIG.5: M is tdependence of the critical size N $_{12}$ (in number of atom s) for positive and negative values of the lattice m is t. The curves are shown in one quadrant for easier comparison.

We conclude that the wetting layer and the 3D islands represent di erent phases which cannot be in equilibrium with each other, and the SK morphology is a result of the replacem ent of one rst order phase transition (vapor { wetting layer) by another rst order transition (vapor { 3D islands). The transfer of matter from the

stable wetting layer to the 3D islands is therm odynam ically unfavored. The experim ental observations m entioned above can be explained on the base of two assum ptions: the therm odynam ic driving force for the coherent 3D islanding is the incomplete wetting and the height of the 3D islands is a discrete variable varying by one m onolayer. This leads to the results that (i) m onolayer high islands with a critical size appear as necessary precursors for 3D islands, (ii) the 2D-3D transition takes place through a series of interm ediate states with discretely increasing thickness that are stable in separate intervals of volume (see Refs. (14,15)) (iii) there exists a criticalm is t below which coherent 3D islands are therm odynam ically unfavored (see Refs. (10,11,12,13)) and the m is t is accommodated by m is t dislocations at a later stage of the growth. Compressed overlayers show a greater tendency to 3D clustering than expanded ones, in agreem ent with experim ental results.¹⁰ Result (i) explains readily why the volum e distribution of InA s/G aA s self-assem bled quantum dots agrees well with the scaling functions for two-dimensional submonolayer hom oepitaxy model.25

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